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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/816,395	04/01/2004	Roy C. Krohn	KRO 0131 PUS1	9594
22045 75	590 10/23/2006		EXAMINER	
BROOKS KUSHMAN P.C. 1000 TOWN CENTER			BERMAN, SUSAN W	
TWENTY-SEC	<del></del>		ART UNIT	PAPER NUMBER
SOUTHFIELD, MI 48075			1711	
			DATE MAILED: 10/23/2004	<b>S</b>

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
Office Action Summary		10/816,395	KROHN, ROY C.			
		Examiner	Art Unit			
		Susan W. Berman	1711			
The MAILING DATE of this Period for Reply	communication a	ppears on the cover sheet with th	e correspondence address			
<ul> <li>after SIX (6) MONTHS from the mailing date</li> <li>If NO period for reply is specified above, the</li> <li>Failure to reply within the set or extended period</li> </ul>	M THE MAILING ne provisions of 37 CFR of this communication. maximum statutory periodicular for reply will, by staturee months after the mai	PLY IS SET TO EXPIRE 3 MONT DATE OF THIS COMMUNICAT 1.136(a). In no event, however, may a reply be dead will apply and will expire SIX (6) MONTHS for the cause the application to become ABANDO ling date of this communication, even if timely	ON. e timely filed from the mailing date of this communication. DNED (35 U.S.C. § 133).			
Status						
1) Responsive to communicate	tion(s) filed on 08	August 2006				
2a) This action is <b>FINAL</b> .	<u> </u>					
3) Since this application is in	☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4) ⊠ Claim(s) <u>1-6,9-19 and 22-3</u> 4a) Of the above claim(s) _ 5) □ Claim(s) is/are allow 6) ⊠ Claim(s) <u>1-6,9-19 and 22-3</u> 7) □ Claim(s) is/are object 8) □ Claim(s) are subject	is/are withdr red. 3 is/are rejected. cted to.	rawn from consideration.				
Application Papers						
	is/are: a) act tany objection to the including the corre	ccepted or b) objected to by the drawing(s) be held in abeyance. ection is required if the drawing(s) is	See 37 CFR 1.85(a). objected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119						
<ul><li>2. Certified copies of th</li><li>3. Copies of the certifie application from the</li></ul>	one of: e priority docume e priority docume d copies of the pri	gn priority under 35 U.S.C. § 119  Ints have been received.  Ints have been received in Application  Ints have been received.	ation No vived in this National Stage			

U.S. Patent and Trademark Office PTOL-326 (Rev. 7-05)

1) Notice of References Cited (PTO-892)

Paper No(s)/Mail Date \_\_\_

2) Notice of Draftsperson's Patent Drawing Review (PTO-948)

3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)

Attachment(s)

4) Interview Summary (PTO-413)
Paper No(s)/Mail Date. \_\_\_\_\_.

6) Other: \_\_\_\_.

5) Notice of Informal Patent Application (PTO-152)

#### Response to Amendment and Arguments

Claim 33 is a now a duplicate of claim 12, which recites the composition of amended claim 1 and a talc.

Applicant argues that the compositions of Shaw et al are for flash evaporation and not for photocuring. This argument is not persuasive because Shaw et al teach flash evaporation for depositing the acrylate monomer on a substrate and then discloses curing the deposited layer of acrylate monomers by exposure to UV irradiation (column 5, lines 49-66). The volatile compounds that applicant discloses are volatile organic solvents. Such solvents are not taught by Shaw et al. Furthermore, Shustack specifically teaches formulations free of solvents (column 10, lines 54-60, and column 11, lines 32-36).

Applicant argues that Shustack fails to disclose the instantly claimed monomer of formula I in claim 1. This argument is not persuasive for the following reasons. Shustack discloses that the compositions comprises homologous monomers, such as tripropylene glycol diacrylate or tetraethylene glycol diacrylate, that are similar in structure and would be expected to have similar properties to monomers of formula I in the instant claims as being reactive diluents for the urethane oligomers in column 6, lines 29-34 and lines 54-57. Shaw et al is relied upon for teaching diethylene glycol di(meth)acrylate monomers in a mixture of a very low and very high viscosity material for providing a protective coating on a metal layer on a dielectric substrate. Applicant argues that the lack of disclosure of a photoinitiator verifies the differing nature between Shaw et al and the instant invention. This argument is not persuasive because it is the combination of Shustack et al and Shaw et al that is at issue. Both patentees teach acrylate-

functional UV curing compositions for coating metals, providing motivation to combine the teachings of the two references.

## Claim Objections

Claim 33 is objected to under 37 CFR 1.75 as being a substantial duplicate of claim 12. Applicant is advised that should claim 12 be found allowable, claim 33 will be objected to under 37 CFR 1.75 as being a substantial duplicate thereof. When two claims in an application are duplicates or else are so close in content that they both cover the same thing, despite a slight difference in wording, it is proper after allowing one claim to object to the other as being a substantial duplicate of the allowed claim. See MPEP § 706.03(k).

### Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-6, 9-11, 13-19 and 22-33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shustack (5,128,387) in view of Shaw et al (5,440,446).

Shustack discloses radiation curable coating compositions for metal comprising a bulky (meth)acrylate monomer, a mixture of urethane acrylate and epoxy acrylate oligomers, an adhesion promoter, an ethylenically unsaturated monomer of the formula set forth in column 5

wherein R<sub>2</sub> can be isobornyl or dicyclopentyl oxyethyl, waxes, other additives and a photoinitiator. See column 3, lines 56, to column 4, line 3, column 5, line 21, to column 6, line 8, line 49. Shustack teaches that the viscosity of the preferred urethane acrylated oligomer is in the range from 2800-4200 cps (column 6, lines 29-41). The viscosity of the preferred epoxy diacrylate oligomer is about 2200 cps (column 7, lines 24-40). A polyester oligomer having a viscosity from 2000-3000 cps is taught in column 8, lines 19-36. Shustack does not teach adding a monomer of formula (I) set forth in instant claim 1; however, Shustack discloses homologous monomers, such as tripropylene glycol diacrylate and tetraethylene glycol diacrylate, in column 6, lines 29-34 and lines 54-57.

Shaw et al disclose a radiation curable acrylate protective coating material for coating a metal layer on a dielectric substrate. Shaw et al teach mixing a very low and very high viscosity material to obtain compositions to be applied by flash evaporation, condensation and cured by exposure to UV radiation. One of the mixtures specifically taught is a mixture of 70% Henkel 4770 (an amine acrylate) and 30% diethylene glycol diacrylate (column 8, line 57, to column 9, line 48). Further advantages of including an amine acrylate are taught in column 9, lines 43-45. See column 6, line 19, to column 9, line 48. Shaw et al teach curing with ultraviolet radiation but do not specifically mention adding a photoinitiator. Waxes are not mentioned.

It would have been obvious to one skilled in the art at the time of the invention to employ the acrylate mixture of an amine acrylate and diethylene glycol diacrylate taught by Shaw et al or to substitute the mixture for the monomers, such as tripropylene glycol diacrylate or tetraethylene glycol diacrylate, in the acrylate materials taught by Shustack. Each of Shustack and Shaw et al teach compositions for coating metal substrates. Shustack provides motivation by

teaching that the compositions comprise monomers homologous to diethylene glycol diacrylate, such as tripropylene glycol diacrylate or tetraethylene glycol diacrylate, in combination with the disclosed acrylated urethane oligomers. Shaw et al provide motivation by teaching that diethylene glycol diacrylate is one of ten diacrylates that can be included in the disclosed composition for forming a film over a metal layer (column 8, lines 6-43). Shaw et al provide additional motivation by teaching that diethylene glycol diacrylate can be used in combination with a higher viscosity amine acrylate to provide a mixture for UV curing on the metal substrate (column 8, line 57, to column 9, line 36). One of ordinary skill in the art at the time of the invention would have been motivated by a reasonable expectation of providing a useful coating composition combining the advantages of the components taught by Shustack and the advantages of the components taught by Shaw et al.

#### **Double Patenting**

The nonstatutory double patenting rejection is based on a judicially created doctrine grounded in public policy (a policy reflected in the statute) so as to prevent the unjustified or improper timewise extension of the "right to exclude" granted by a patent and to prevent possible harassment by multiple assignees. See *In re Goodman*, 11 F.3d 1046, 29 USPQ2d 2010 (Fed. Cir. 1993); *In re Longi*, 759 F.2d 887, 225 USPQ 645 (Fed. Cir. 1985); *In re Van Ornum*, 686 F.2d 937, 214 USPQ 761 (CCPA 1982); *In re Vogel*, 422 F.2d 438, 164 USPQ 619 (CCPA 1970); and *In re Thorington*, 418 F.2d 528, 163 USPQ 644 (CCPA 1969).

A timely filed terminal disclaimer in compliance with 37 CFR 1.321(c) may be used to overcome an actual or provisional rejection based on a nonstatutory double patenting ground provided the conflicting application or patent is shown to be commonly owned with this application. See 37 CFR 1.130(b).

Effective January 1, 1994, a registered attorney or agent of record may sign a terminal disclaimer. A terminal disclaimer signed by the assignee must fully comply with 37 CFR 3.73(b).

Claims 1-6, 9-19 and 22-33 are provisionally rejected under the judicially created doctrine of obviousness-type double patenting as being unpatentable over claims 1-13,15-25 and 27-30 of copending Application No. 10/703,938. Although the conflicting claims are not identical, they are not patentably distinct from each other for the following reasons. The claims of '938 set forth the same components as are set forth in the instant claims except that the formula of the "acrylated monomer" is not specified as in the instant claims. Claims 28-30 of '938 sets forth an ethylene glycol dicyclopentyl ether acrylate.

This is a <u>provisional</u> obviousness-type double patenting rejection because the conflicting claims have not in fact been patented.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Susan W. Berman whose telephone number is 571 272 1067. The examiner can normally be reached on M-F 9:30-6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, James Seidleck can be reached on 571 272 1078. The fax phone number for the organization where this application or proceeding is assigned is 571 273 8300.

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SB

10/16/06

Susan W Berman Primary Examiner

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